(12) INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(19) World Intellectual Property Organization

International Bureau

(43) International Publication Date 24 February 2011 (24.02.2011)



(10) International Publication Number WO 2011/022639 A2

(51) International Patent Classification:

C03C 3/091 (2006.01) C03C 3/04 (2006.01)

C03C 3/087 (2006.01) C03C 3/083 (2006.01)

C03C 3/085 (2006.01)

(21) International Application Number:

PCT/US2010/046153

(22) International Filing Date:

20 August 2010 (20.08.2010)

(25) Filing Language:

English

(26) Publication Language:

English

(30) Priority Data:

61/235,762

21 August 2009 (21.08,2009) US

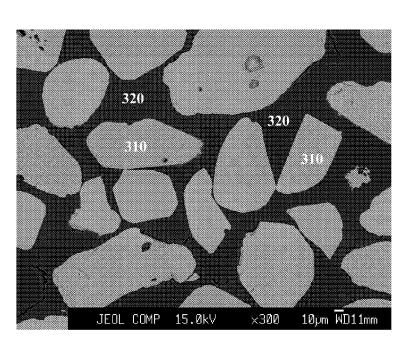
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- (81) Designated States (unless otherwise indicated, for every kind of national protection available): AE, AG, AL, AM, AO, AT, AU, AZ, BA, BB, BG, BH, BR, BW, BY, BZ, CA, CH, CL, CN, CO, CR, CU, CZ, DE, DK, DM, DO, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, GT, HN, HR, HU, ID, IL, IN, IS, JP, KE, KG, KM, KN, KP, KR, KZ, LA, LC, LK, LR, LS, LT, LU, LY, MA, MD, ME, MG, MK, MN, MW, MX, MY, MZ, NA, NG, NI, NO, NZ, OM, PE, PG, PH, PL, PT, RO, RS, RU, SC, SD,

[Continued on next page]

(54) Title: ZIRCON COMPATIBLE GLASSES FOR DOWN DRAW

FIG. 4



(57) Abstract: A glass that is downdrawable and ion exchangeable. The glass has a temperature T35kp at which the viscosity is 35 kilopoise. T35kp is less than the breakdown temperature T^{breakdown} of zircon.



- SE, SG, SK, SL, SM, ST, SV, SY, TH, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, ZA, ZM, ZW.
- (84) Designated States (unless otherwise indicated, for every kind of regional protection available): ARIPO (BW, GH, Published: GM, KE, LR, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European (AL, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HR, HU, IE, IS, IT, LT, LU,

LV, MC, MK, MT, NL, NO, PL, PT, RO, SE, SI, SK, SM, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

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ZIRCON COMPATIBLE GLASSES FOR DOWN DRAW

CROSS-REFERENCE TO RELATED APPLICATIONS

[0001] This application claims the benefit of priority under 35 U.S.C. § 119(e) of U.S. Provisional Application Serial No. 61/235,762 filed on August 21, 2009.

BACKGROUND

[0002] Ion-exchangeable glasses can be manufactured in several forms by a variety of processes. In particular, such glasses can be drawn into thin sheets via either slot-draw or fusion-draw processes.

[0003] Current fusion-draw designs require zircon refractory lining and hardware for isopipes. Most ion-exchangeable glasses react with the zircon, breaking it down into silica, which dissolves in the glass, and zirconia, which forms solid inclusions that are entrained by flow into the molten glass and ends up in the final product. The attack of zircon by the molten glass continues over time and the level or concentration of zirconia inclusions in the glass increases. Because these inclusions are concentrated on the fusion line, they are also located at the point of maximum central tension after ion exchange, potentially compromising the strength of the ion-exchanged glass part. Moreover, in applications, such as in hand-held electronic devices such as PDAs, mobile phones, etc., in which small pixels of light are to be directed through the glass sheet, the high refractive index of the zirconia inclusions can block pixels. In very thin (e.g., ≤ 1mm thick) glass sheets, the zirconia inclusions are visible to the human eye, and constitute cosmetic defects that, in some instances, result in rejection of the part.

SUMMARY

[0004] What is provided and described herein is a glass that is down-drawable and ion exchangeable. The glass has a temperature T^{35kp} at which the viscosity is 35 kilopoise. T^{35kp} is less than the breakdown temperature $T^{breakdown}$ of zircon.

[0005] Accordingly, one aspect of the disclosure is to provide a glass. The glass comprises SiO_2 and Na_2O and has a temperature T^{35kp} at which the glass has a viscosity of 35 kpoise, wherein the temperature $T^{breakdown}$ at which zircon breaks down to form ZrO_2 and SiO_2 is greater than T^{35kp} .

[0006] A second aspect of the disclosure is to provide a glass. The glass comprises SiO_2 and Na_2O and having a temperature T^{35kp} at which the glass has a viscosity of 35 kpoise, wherein $SiO_2 + B_2O_3 \ge 66$ mol% and $Na_2O \ge 9$ mol%, and wherein the temperature $T^{breakdown}$ at which zircon breaks down to form ZrO_2 and SiO_2 is greater than T^{35kp} .

[0007] A third aspect of the disclosure is a fusion-drawn glass sheet that is substantially free of fusion line zirconia defects.

[0008] These and other aspects, advantages, and salient features will become apparent from the following detailed description, the accompanying drawings, and the appended claims.

BRIEF DESCRIPTION OF THE DRAWINGS

[0009] FIGURE 1 is a plot of measured vs. predicted zircon breakdown temperature T^{breakdown};

[0010] FIGURE 2 is a plot of measured values vs. predicted 35kp temperatures T^{35kp};

[0011] FIGURE 3 is a backscattered electron micrograph of a mixture of zircon and a glass composition (composition 5, Table 1) following heat treatment at 1175°C for 114 hours; and

[0012] FIGURE 4 is a backscattered electron micrograph of a mixture of zircon and a glass composition (composition 11, Table 1) following heat treatment at 1175°C for 114 hours.

DETAILED DESCRIPTION

[0013] In the following description, like reference characters designate like or corresponding parts throughout the several views shown in the figures. It is also understood that, unless otherwise specified, terms such as "top," "bottom," "outward," "inward," and the like are words of convenience and are not to be construed as limiting terms. In addition, whenever a group is described as comprising at least one of a group of elements and combinations thereof, it is understood that the group may comprise, consist essentially of, or consist of any number of those elements recited, either individually or in combination with each other. Similarly, whenever a group is described as consisting of at least one of a group of elements or combinations thereof, it is understood that the group may consist of any number of those elements recited, either individually or in combination with each other. Unless otherwise specified, a range of values, when recited, includes both the upper and lower limits of the range.

[0014] Referring to the drawings in general, it will be understood that the illustrations are for the purpose of describing particular embodiments and are not intended to limit the disclosure or appended claims thereto. The drawings are not necessarily to scale, and certain features and certain views of the drawings may be shown exaggerated in scale or in schematic in the interest of clarity and conciseness.

[0015] If the temperature at which the zircon in the isopipe breaks down to form zirconia and silica (also referred to herein as the "breakdown temperature" or "T^{breakdown}") were higher than any temperature seen on the isopipe, the problem of zirconia inclusions in fusion-drawn glass (also referred to as "fusion line zirconia") would not occur. In this instance, the temperatures used to form the glass over the isopipe would be too low to create zirconia, and no such defect could form in the glass.

[0016] Because fusion is essentially an isoviscous process, the highest temperature seen by the glass corresponds to a particular viscosity of the glass. In those standard fusion-draw operations known in the art, this viscosity is about 35,000

poise ("35 kpoise" or "35 kp"), although the viscosity can be as low as about 16,000 poise during brief periods when an isopipe is being initially wet by glass. We define the difference between the breakdown temperature and the temperature corresponding to 35,000 poise viscosity as the breakdown margin T^{margin}, where:

$$T^{\text{margin}} = T^{\text{breakdown}} - T^{35\text{kp}}$$
, (1)

where T^{35kp} is the temperature at which the viscosity of the glass is 35,000 poise.

[0017] When the breakdown margin T^{margin} is negative, zircon will breakdown to form zirconia defects at some location on the isopipe. When T^{margin} is zero, it is still possible that temperature excursions could cause zircon breakdown to occur. It is therefore desirable not only to make the breakdown margin positive, but to maximize T^{margin} as much as possible while being consistent with all the other attributes that must be maintained in the final glass product.

[0018] To understand the relationship between breakdown temperature and 35 kp temperature, it is helpful to consider the reaction to form zirconia from zircon. The reaction is written thus:

$$ZrSiO_4(xtal) \rightarrow ZrO_2(xtal) + SiO_2(liq)$$
, (2)

where $ZrSiO_4(xtal)$ and $ZrO_2(xtal)$ are crystalline zircon and zirconia, respectively, and $SiO_2(liq)$ is liquid silica, which dissolves into the glass, produced by reaction (2).

The breakdown of zircon can be prevented by driving reaction (2) to the left. To do so, the activity (i.e., the concentration) of at least one of ZrO₂ or SiO₂ in the glass is increased. To accomplish this via ZrO₂ addition, the concentration of ZrO₂ would have to be increased until zircon became the liquidus phase. This, however, would risk creating a new, unwanted defect, secondary zircon. The remaining option is to increase the activity/concentration of SiO₂ in the glass. As SiO₂ increases at the expense of other glass components, however, the glass viscosity increases as well. Thus, the rate at which breakdown temperature increases must be balanced against the rate at which the 35 kp temperature T^{35kp} increases.

[0020] In one aspect, a glass composition having a breakdown temperature $T^{breakdown}$ that is higher than the 35 kp temperature T^{35kp} – i.e., $T^{breakdown} > T^{35kp}$ – is provided. The breakdown temperature is preferably higher than any viscosity that might be obtained – however briefly – during normal operation of a fusion-draw process. The composition is, in one embodiment, meltable in a conventional electric-boost, zirconia or alumina-refractory tank; i.e., the melt temperature T^{350p} (i.e., the temperature corresponding to a viscosity of about 350 poise) of the glass is less than about $1650^{\circ}C$.

[0021] In one embodiment, the glass described herein, in addition to being down-drawable and compatible with fusion-draw processes, is ion-exchangeable so as to produce a compressive layer on the glass surface of at least 20 µm in depth and having a maximum compressive stress of at least 350 MPa. In other embodiments, the glass is ion-exchangeable so as to produce a central tension within the glass of at least 10MPa. The glass comprises SiO_2 and Na_2O , wherein $SiO_2 + B_2O_3 \ge 66$ mol%, and $Na_2O \ge 9$ mol%. The glass, in some embodiments, further comprises at least one of B₂O₃, K₂O, MgO, and CaO. In a particular embodiment, the glass comprises: 61 $\text{mol } \% \leq \text{SiO}_2 \leq 75 \text{ mol}\%$; 7 $\text{mol } \% \leq \text{Al}_2\text{O}_3 \leq 15 \text{ mol}\%$; 0 $\text{mol}\% \leq \text{B}_2\text{O}_3 \leq 12 \text{ mol}\%$; 9 mol $\% \le \text{Na}_2\text{O} \le 21 \text{ mol}\%$; 0 mol $\% \le \text{K}_2\text{O} \le 4 \text{ mol}\%$; 0 mol $\% \le \text{MgO} \le 7 \text{ mol}\%$; and 0 mol% \le CaO \le 3 mol%. The glass, in some embodiments, further comprises at least one fining agent such as, but not limited to, a halogen or a multivalent fining agent such as As₂O₃, Sb₂O₃, SnO₂, and Fe₂O₃. In a particular embodiment, the total concentration of As₂O₃ and Sb₂O₃, if either or both are present, is less than 500ppm by weight.

[0022] The breakdown margin T^{margin} of the glass is given by the expression

$$\begin{split} T^{margin}\left(^{\circ}C\right) &= 610.6 - 41.0[Al_{2}O_{3}] + 9.9[B_{2}O_{3}] - 3.5[Na_{2}O] - 20.2[K_{2}O] - 25.6[MgO] \\ &+ 34.2[CaO] \quad , \quad (3) \end{split}$$

where the concentrations [Al₂O₃], [B₂O₃], [Na₂O], [K₂O], [MgO], and [CaO] are expressed in mol%.%. The coefficients in equation (3) have been further refined to yield the expression

$$\begin{split} &T^{margin}\left(^{\circ}C\right)=446.6-50.2[Al_{2}O_{3}]+22.6[B_{2}O_{3}]-4.4[Na_{2}O]-3.9[K_{2}O]-1.2[MgO+CaO] \end{aligned}$$
 CaO] . (3a)

The SiO_2 concentration is substantially accounted for by difference from the other oxides and is therefore not included in this expression. When the condition in equation (3) is satisfied, the breakdown temperature for zircon will be greater than the 35kp temperature of the glass (i.e., $T^{breakdown} > T^{35kp}$), and fusion-line zirconia defects can thus be avoided when the glass is formed over a zircon isopipe in the fusion process.

[0023] As can be seen from the regression coefficients in equation (3), the only oxide that contributes positively to breakdown margin T^{margin} is B_2O_3 . In order to avoid excessively low breakdown temperatures, lower SiO_2 concentrations require higher B_2O_3 concentrations, since SiO_2 is the strongest contributor to high breakdown temperatures. The linkage between B_2O_3 and SiO_2 results in a more fundamental constraint on glass composition, namely, $SiO_2 + B_2O_3 \ge 66 \text{ mol}\%$.

[0024] Na₂O is the essential oxide component for facilitating ion exchange, as it is removed from the glass and replaced by larger monovalent cations such as, for example, K_2O during conventional ion exchange in a molten salt such as, for example, potassium nitrate (KNO₃). In order to obtain the minimum useful compressive stress, Na₂O \geq 9 mol%.

[0025] While it is desirable that the glasses described herein be compatible with existing melting processes, alternative means of melting or alternative batch materials that would enable melting harder glasses may also be used to prepare these glasses. To keep melt temperatures from becoming too high, fluxes (e.g., B₂O₃, alkali oxides, and alkaline earth oxides) can be kept at relatively high levels with respect to the basic glass formers Al₂O₃ and SiO₂. This can be understood from the fact that the 35 kp and 350 p temperatures "track" each other – i.e., a high 35 kp temperature also implies a high 350 p temperature. From regression equation (5) for 35 kp (shown in paragraph [0032] below), high Al₂O₃ contents and, by inference, high SiO₂ contents lead to high 35 kp temperatures, and therefore to high melt temperatures. To avoid

higher melt temperatures, it is desirable that $B_2O_3 + Na_2O + K_2O + MgO + CaO \ge 18$ mol%. With the exception of MgO, all of the above components also contribute to low liquidus temperature, which ensures a liquidus viscosity that is high enough to be compatible with fusion-draw processes.

[0026] In one aspect, it is desirable that the liquidus temperature be as low as reasonably achievable to ensure a high liquidus viscosity. The relationship between liquidus temperature and composition is exceptionally complex, and no simple algorithm can be devised to account for it. However, liquidus temperature generally decreases as the concentration of alkali metal oxides in excess of aluminum (i.e., $Na_2O + K_2O - Al_2O_3$) increases, and as sodium is replaced by potassium, at least within the ranges indicated above. Likewise, liquidus temperature decreases steeply with increasing B_2O_3 . Therefore, it is advantageous that $B_2O_3 + Na_2O + K_2O - Al_2O_3 \ge 0$ to ensure that the glass have suitably low liquidus temperature.

[0027] The glasses described herein may be fusion drawn into sheets that can be used as cover plates, windows, casings, screens, touch panels, or the like, for mobile electronic devices, such as telephones, entertainment devices, including games, music players and the like; information terminal (IT) devices, such as laptop computers; and analogous stationary versions of such devices.

One of several methods. In one method, known as the gradient strip test, a glass sample of interest is crushed and sieved to obtain a size fraction of generally less than 20 mesh. A strip of 1390 zircon refractory (Cohart) is placed in the bottom of a long, narrow platinum boat and the crushed glass is placed on top of the zircon refractory. The boat containing the refractory and glass is then loaded into a conventional gradient tube furnace that has been calibrated so that the temperature at each point in the furnace can be mapped to a specific place along the length of the boat. The gradient is set such that the low end of the furnace is at a temperature in a range from about 750°C up to about 800°C, and the hot end is at a temperature in a range from about 1225°C up to about 1300°C. The boat remains in the furnace for one week. After one week in the furnace, the boat is removed and the glass/refractory slab is

sectioned along its length and inspected. Zirconia inclusions in the glass can be distinguished from zircon using polarized light microscopy, and further confirmation can be obtained via scanning electron microscopy. Because the furnace temperature is known along the length of the sample, the location at which zirconia first appears corresponds to a particular temperature. The estimated uncertainty in the temperature is about $\pm 10^{\circ}$ C.

[0029]Compositions of glasses evaluated by the gradient strip test method are shown in Table 1, and plotted vs. predicted breakdown temperature in FIG. 1. Compositions listed in Table 1 are expressed in mol%. In FIG. 1, the y-error bars denote the measurement uncertainty of 10°C, and the x-error bars denote the 2σ standard error – 15°C – of the regression equation. The compositions listed in Table 1 are expressed in mol% and, for most of the glasses listed, are the nominal compositions. The true compositions and nominal compositions should be close for most of the glasses listed in Table 1, but for the highest boron glasses the melting process itself may well have reduced the B₂O₃ content of the glasses. In several cases, the breakdown temperatures ("Breakdown T") were higher than the temperature at the hot end of the gradient furnace. In these instances, it can only be established that the breakdown temperature T^{breakdown} was higher than the temperature of the hot end, and a unique temperature for T^{breakdown} cannot be assigned. For three of the samples (25, 26, 27) listed in Table 1, the high coefficient of thermal expansion of the glasses caused heavy crizzling or crazing of the glass at the glass-refractory interface. Consequently, it could only be determined that, for these samples, zirconia was present at up to about 1100°C, but the temperature (presumably lower) at which zircon became stable could not be determined.

[0030] Table 1 also lists predicted breakdown temperatures that were obtained by linear regression of the breakdown temperature against the mole fractions of all the major element oxides except SnO₂ (frequently present at a low level as a fining agent and SiO₂. SiO₂ was left out of the regression because its concentration is substantially accounted for by difference from the other oxides. The regression equation describing breakdown temperature vs. composition is as follows:

$$T^{breakdown}(predicted) (^{\circ}C) = 2095.1 - 24.0[Al_2O_3] - 8.5[B_2O_3] - 33.6[Na_2O] - 46.2[K_2O - 24.7[MgO] - 23.9[CaO], (4)$$

where the concentrations in brackets are expressed in mol%. The coefficients in equation (4) have been further refined to yield the expression:

$$T^{breakdown}(predicted) \ (^{\circ}C) = 2008.8 - 23.5[Al_2O_3] - 1.6[B_2O_3] - 33.6[Na_2O] - 45.5[K_2O] - 10.5[MgO + CaO] \ . \ (4a)$$

The standard error of the regression in equations (4) and (4a) is about 7.3° C. The 2σ uncertainty is therefore about 15° C, which is close to the estimated uncertainty of the measurement itself.

[0031] Zircon breakdown temperature can also be experimentally determined by the isothermal hold technique. In this method, glass samples are placed in small platinum boats containing zircon refractory and held at a fixed temperature for a one week duration. While the isothermal hold method does not provide a unique temperature for zircon breakdown, it does serve as a screening tool. If it is known in advance that the breakdown temperature must be higher than a threshold value, then simply holding the glass sample and several other compositions simultaneously at the threshold temperature can be used to identify those samples having breakdown temperatures either above or below the threshold temperature.

Results of isothermal hold tests for glass compositions are listed in Table 2. Compositions listed in Table 2 are expressed in mol%. For nearly all of the samples listed, the compositions in Table 2 are nominal rather than measured values. The breakdown temperature of a sample cannot be uniquely determined via this technique. However, if zirconia is not observed, the breakdown temperature must be greater than the hold temperature. Likewise, if zirconia is observed, then the breakdown temperature must be lower than the isothermal hold temperature. The "sense" of the breakdown temperature relative to the hold temperature (i.e., greater or less than the hold temperature listed under "Breakdown T" in Table 2) is indicated in Table 2. The breakdown temperature calculated using the model previously described herein is also shown for comparison. For 75 samples listed in Table 2, the predicted

breakdown temperature has the correct sense relative to the hold temperature; i.e., if the predicted temperature is greater than the hold temperature, then no zirconia is seen. Likewise, if the predicted temperature is less than the hold temperature, then varying amounts of zirconia is observed.

[0033] The difference between conventional glass having a low breakdown temperature and a glass having a high breakdown temperature, such as those disclosed herein is illustrated in FIGS. 3 and 4. FIG. 3 shows a backscattered electron micrograph of a glass composition (composition 5 in Table 1) having a low breakdown temperature, and FIG. 4 shows a backscattered electron micrograph of a glass compositions (composition 11 in Table 1) having a high zircon breakdown temperature. Both glasses were mixed with zircon grains and loaded into Pt boats, which were then placed in a furnace at 1175°C for 114 hrs. The samples were then removed form the furnace, air quenched, and later cut and polished for inspection. As seen in FIG. 3, the sample containing glass composition 5, which has a breakdown temperature of 1105°C, clearly shows zirconia grains resulting from zircon breakdown. The zircon has reacted with the glass, as evidenced by the decoration of each of the zircon grains 310 (the grey phase in FIG. 3) with a large number of smaller zirconia grains 330 (white phase) just inside the glass 320 (dark phase). In contrast, the sample containing glass composition 11, which has a breakdown temperature of 1180°C, did not undergo zircon breakdown. FIG. 4 shows that zircon grains 310 and glass are present, but no zirconia grains were observed.

[0034] Relative amounts of zirconia observed for each sample are also listed in Table 2, and are described in relative amounts ("High," Medium," "Trace," and "None"). The relative amounts of zirconia observed also track the breakdown temperature. If $T^{breakdown}$ is predicted to be much lower than the hold temperature, a large amount of zirconia is observed. When the predicted $T^{breakdown}$ is close to the isothermal hold temperature, only a trace of zirconia is observed. In the last ten samples listed in Table 2, the predicted sense of the breakdown temperature is not the same as observed, but all are within 2σ of the predicted breakdown temperature, and hence within the uncertainty of the prediction.

[0035]Two deficiencies are associated with the gradient strip and isothermal hold tests. First, the long exposures at high temperature that are used in both tests can produce volatilization of certain glass components – particularly B₂O₃ – which can in turn impact the breakdown temperature of the glass. As discussed hereinabove, an increase in SiO₂ causes the breakdown temperature to increase. Since SiO₂ typically comprises more than 60 mol% of all the oxides present in the glasses described herein, the absolute SiO₂ concentration in the glass increases the most when a volatile component such as B₂O₃ is lost. Furthermore, at least one volatile component from a glass containing both Na₂O and B₂O₃ is Na₂B₄O₇, so both sodium and boron can be lost. Thus, the breakdown temperature for a glass having a high B₂O₃ concentration is likely to be an overestimate of the actual T^{breakdown} and the glass composition should be verified following the test. Second, the breakdown of zircon is very slow. Consequently, the one week hold time used in both types of tests may in some cases be insufficient to reveal an observable degree of breakdown. In general, both of these problems lead to observation of higher-than-expected breakdown temperatures.

[0036] Viscosity measurements were separately performed on a broad composition range of ion-exchangeable glasses. When the temperature is regressed to the temperature at which the viscosity of the glass is 35,000 poise (T^{35kp}), a linear correlation with composition is obtained:

$$T^{35kp}$$
 (°C) = 1484.5 + 17.1[Al₂O₃] - 18.4[B₂O₃] - 30.1[Na₂O] - 26.0 [K₂O] + 0.9[MgO] - 58.1[CaO] , (5)

with a standard error of 5.8°C, and thus a propagated 2σ uncertainty of 11.6°C. Measured values of T^{35kp} are plotted against predicted 35 kp temperatures in FIG. 2, and show good correlation between values predicted in equation (5) and measured values. The coefficients in equation (5) have been further refined to yield the expression:

$$T^{35kp} (^{\circ}C) = 1562.2 + 26.7[Al_2O_3] - 24.2[B_2O_3] - 38[Na_2O] - 41.6 [K_2O] - 9.3[MgO + CaO] . (5a)$$

[0037] Since the breakdown temperature T^{breakdown} exceeds the 35kp temperature T^{35kp}, equations (1), (4), and (5) are combined to give equation (3):

$$T^{margin} = 610.6 - 41.0[Al_2O_3] + 9.9[B_2O_3] - 3.5[Na_2O] - 20.2[K_2O] - 25.6[MgO] + 34.2[CaO] . (3)$$

The coefficients in equation (3) have been further refined to yield equation (3a):

$$\begin{split} &T^{margin}\left(^{\circ}C\right)=446.6-50.2[Al_{2}O_{3}]+22.6[B_{2}O_{3}]-4.4[Na_{2}O]-3.9[K_{2}O]-1.2[MgO+CaO] \end{aligned} \label{eq:caO}$$

Exemplary glasses that satisfy equation (3) are listed in Table 3. Compositions listed in Table 3 are expressed in mol%.

[0038] In some embodiments, it is desirable that the zircon breakdown temperature is as high as possible, and preferably a temperature that is greater than any experienced on the isopipe. The propagated 2σ uncertainty is 19°C. To ensure that the breakdown temperature will be greater than any temperature in the isopipe, 19°C can be subtracted from the regression coefficient in equations (3) and (3a) to account for any uncertainty:

$$T^{margin} = 591.6 - 41.0[Al_2O_3] + 9.9[B_2O_3] - 3.5[Na_2O] - 20.2[K_2O] - 25.6[MgO] + 34.2[CaO] , (6)$$

$$T^{\text{margin}} (^{\circ}\text{C}) = 427.6 - 50.2[\text{Al}_2\text{O}_3] + 22.6[\text{B}_2\text{O}_3] - 4.4[\text{Na}_2\text{O}] - 3.9[\text{K}_2\text{O}] - 1.2[\text{MgO} + \text{CaO}]$$
 (6a)

[0039] There is, however, sufficient flexibility in the fusion process to deliver glass at viscosities that are both lower and higher than 35kp. Equation (3) could therefore be adopted, aiming for as high a breakdown margin T^{margin} as possible. The glass delivery temperature could then be adjusted if the required product attributes do not produce a predicted breakdown margin T^{margin} of greater than 19°C.

[0040] The glass compositions listed in Table 3 have a 350 poise temperature T^{350} (i.e., the temperature at which the glass is typically melted) that is less than or equal to 1650°C, which is desirable for reducing gaseous and solid inclusions at

production scale melt rates. In addition, all of the compositions are ion exchangeable by those methods widely known in the art. In the ion exchange process, smaller metal ions in the glass are replaced or "exchanged" by larger metal ions of the same valence within a layer that is close to the outer surface of the glass. The replacement of smaller ions with larger ions creates a compressive stress within the layer. In one embodiment, the metal ions are monovalent alkali metal ions (e.g., Na⁺, K⁺, Rb⁺, and the like), and ion exchange is accomplished by immersing the glass in a bath comprising at least one molten salt of the larger metal ion that is to replace the smaller metal ion in the glass. Alternatively, other monovalent ions such as Ag⁺, Tl⁺, Cu⁺, and the like may be exchanged for monovalent ions. The ion exchange process or processes that are used to strengthen the glass can include, but are not limited to, immersion in a single bath or multiple baths of like or different compositions with washing and/or annealing steps between immersions.

[0041] In one embodiment, the glasses listed in Table 3 are ion exchanged by exposure to molten KNO₃ at a temperature of 410° C for 8 hours to produce a compressive stress layer having a depth (also referred to as a "depth of layer") of at least 20 μ m on the surface of the glass and a maximum compressive stress of at least 350 MPa. In another embodiment the glasses listed in Table 3 are ion exchanged to achieve a central tension of at least 10 MPa.

Table 1. Gradient strip zircon breakdown temperatures.

		- г			- г					Predicted	
									Breakdown	breakdown	Breakdown
Sample	SiO_2	Al_2O_3	$\mathrm{B_2O_3}$	Na_2O	K_2O	MgO	CaO	SnO_2	T (°C)	T(°C)	margin (°C)
1	61.94	13.99	5.99	13.99	2	2	0	0.1	1095	1096	-46
2	63.94	11.99	5.99	15.98	2	0	0	0.1	1115	1126	81
3	64.09	13.2	5.66	12.25	2.83	1.89	0	0.09	1140	1141	-24
4	63.94	11.99	5.99	13.99	2	2	0	0.1	1150	1144	37
5	66.12	10.19	0.58	14.16	2.37	5.75	0.59	0.21	1105	1103	-27
6	66.01	11.25	0.6	14.2	1.35	4.76	1.61	0.2	1120	1124	10
7	67.34	12.33	0	20.33	0	0	0	0	1125	1115	32
8	67.85	9.21	0.54	14.16	2.34	5.22	0.46	0.19	1140	1145	23
9	64.8	12.8	4.8	17.6	0	0	0	0	1150	1155	70
10	68.07	9.72	0.57	13.21	2.31	5.39	0.54	0.18	1160	1160	4
11	68.68	9.54	0.56	12.92	2.27	5.29	0.53	0.18	1180	1178	16
12	69.25	9.03	0.39	13.41	2.21	5.04	0.47	0.18	1185	1186	39
13	62.26	13.27	9.6	14.87	0	0	0	0	1195	1195	108
14	70.25	8.86	0	13.43	1.67	5.18	0.41	0.17	1210	1216	47
15	70.19	8.6	0	14.28	1.19	5.1	0.44	0.18	1215	1217	67
16	70.72	8.67	0	13	2.16	5.19	0.05	0.17	1220	1220	34
17	69.96	8.60	0.55	14.03	1.21	4.97	0.45	0.20	1215	1222	77
18	69.85	8.71	0.05	14.27	1.26	5.18	0.47	0.19	1200	1208	61
19	69.86	8.65	0.03	14.17	1.2	5.05	0.49	0.18	1220	1219	69
20	70.11	8.68	0.03	14.22	1.2	5.06	0.49	0.18	1215	1216	67
21	69.25	9.03	0.39	13.41	2.21	5.04	0.47	0.18	1190	1186	39
22	69.41	8.55	0	14.05	1.19	6.17	0.44	0.19	1215	1199	43
23	65.19	10.19	6.2	12.06	2.68	1.81	0.78	0.1	1215	1205	137
24	70.92	8.52	0	13.7	1.17	5.11	0.36	0.19	>1245	1241	70
25	62.97	8.91	2.23	15.46	4.84	5.34	0.08	0.15	<1090	985	-20
26	64.88	9.18	2.29	14.43	3.49	5.49	0.07	0.15	<1100	1071	-3
27	64.87	9.18	8.0	14.42	4.99	5.5	0.07	0.15	<1100	1015	-49
28	72.16	8.13	0	13.27	1.03	4.81	0.42	0.16	>1245	1277	100
29	73.51	7.6	0	11.58	2.3	4.2	0.6	0.2	>1250	1299	124
30	73.14	7.19	0	12.54	2.16	4.72	0.05	0.18	>1250	1283	108
31	73.52	7.6	0	13.87	0	4.2	0.61	0.2	>1260	1328	163
32	65.7	8	10	15.7	0.6	0	0	0.08	>1260	1262	314
33	65.91	10.3	6.27	12.19	2.71	1.83	0.79	0.1	1230	1195	132

Table 2. Results from isothermal zircon breakdown experiments.

									Zirconia	Breakdown T	Predicted breakdown
Sample	SiO_2	Al_2O_3	$B2O_3$	Na_2O	K_2O	MgO	CaO	SnO_2	amount	(°C)	T(°C)
34	65	11.25	0.6	14.25	2.35	5.75	0.6	0.2	High	<1150	1076
35	64	12.25	0.6	14.25	2.35	5.75	0.6	0.2	High	<1150	1052
36	64	11.25	0.6	14.25	2.35	5.75	1.6	0.2	High	<1150	1052
37	62	12.25	0.6	14.25	2.35	5.75	2.6	0.2	High	<1150	1004
6	66	11.25	0.6	14.25	1.35	4.75	1.6	0.2	Trace	<1150	1123
38	66	12.25	0.6	14.25	0.35	3.75	2.6	0.2	Medium	<1150	1146
39	66	11.3	0.6	14.2	1.4	5.2	1.1	0.2	Medium	<1150	1122
40	66	11.3	0.6	14.2	1.4	5.7	0.6	0.2	Medium	<1150	1121
41	65.35	11.19	1.58	14.06	1.34	4.7	1.58	0.2	Medium	<1150	1124
42	65.34	11.19	1.58	14.06	1.39	5.15	1.09	0.2	Medium	<1150	1122
29	73.5	7.6	0	11.6	2.3	4.2	0.6	0.2	None	>1190	1298
43	72.55	8.2	0	11.8	2.3	4.35	0.6	0.2	None	>1190	1273
44	71.6	8.85	0	12	2.3	4.45	0.6	0.2	None	>1190	1248
45	70.7	9.45	0	12.2	2.3	4.55	0.6	0.2	None	>1190	1225
46	69.75	10.05	0	12.4	2.3	4.7	0.6	0.2	None	>1190	1200
47	69.87	8.77	0.56	12.67	2.27	5.14	0.53	0.18	None	>1170	1209
48	71.04	8	0.56	12.42	2.27	4.99	0.53	0.18	None	>1170	1240
49	72.22	7.22	0.56	12.17	2.27	4.84	0.53	0.18	None	>1170	1270
50	5170.43	8.77	0	12.67	2.27	5.14	0.53	0.18	None	>1170	1214
51	71.61	7.99	0	12.42	2.27	4.99	0.53	0.18	None	>1170	1245
52	72.78	7.22	0	12.17	2.27	4.84	0.53	0.18	None	>1170	1275
16	70.72	8.67		13	2.16	5.19	0.05	0.17	None	>1190	1220
53	71.61	7.99	0	12.95	2.27	4.99	0	0.18	None	>1190	1239
30	73.14	7.19		12.54	2.16	4.72	0.05	0.18	None	>1190	1283
54	72.22	7.22	0	12.17	3.36	4.84	0	0.18	None	>1190	1238
55	72.22	7.22	0	14.26	2.27	3.84	0	0.18	None	>1190	1242
56	72.22	7.22	0	13.26	3.27	3.84	0	0.18	None	>1190	1230
57	73.5	7.6	0	12.75	1.15	4.2	0.6	0.2	None	>1200	1312
58	73.5	7.6	0	13.9	0	4.2	0.6	0.2	None	>1200	1327
59	72.55	8.2	0	12.95	1.15	4.35	0.6	0.2	None	>1200	1288
60	72.55	8.2	0	14.1	0	4.35	0.6	0.2	None	>1200	1302
61	73.94	7.65	0	13.98	0	4.23	0	0.2	None	>1200	1337
62	72.98	8.25	0	14.19	0	4.38	0	0.2	None	>1200	1311
63	73.5	7.6	0	11.6	2.3	4.2	0.6	0.2	None	>1200	1298
31	73.5	7.6	0	13.9	0	4.2	0.6	0.2	None	>1200	1327
64	62.93	12.99	5	16.98	2	0	0	0.1	Medium	<1100	1077
65	61.94	13.99	5.99	15.98	2	0	0	0.1	High	<1150	1078
66	61.93	13.99	5.99	13.99	4	0	0	0.1	High	<1150	1053
67	61.93	13.99	5.99	13.99	2	2	0	0.1	Medium	<1150	1096
68	61.93	13.99	5	16.98	2	0	0	0.1	High	<1150	1053
69	61.93	13.99	4	17.98	2	0	0	0.1	High	<1150	1028
8	67.87	9.21	0.54	14.16	2.34	5.22	0.46	0.19	Trace	<1170	1145
70	67.732	9.696	0.6185	13.336	2.3738	5.5414	0.4871	0.1855	Trace	<1170	1150

									Zirconia	Breakdown T	Predicted breakdown
Sample	SiO_2	Al_2O_3	$B2O_3$	Na ₂ O	K_2O	MgO	CaO	SnO_2	amount	(°C)	T(°C)
71	68.67	8.54	0.56	13.96	2.27	5.29	0.53	0.18	Trace	<1190	1167
72	71.15	7.78	0.51	12.93	2.09	4.87	0.49	0.18	None	>1190	1240
73	71.16	8.03	0	13.18	2.09	4.87	0.49	0.18	None	>1190	1230
74	63.94	12.99	8.99	13.99	0	0	0	0.1	None	>1200	1236
75	63.94	13.49	8.99	13.49	0	0	0	0.1	None	>1200	1241
76	63.94	13.99	8.99	12.99	0	0	0	0.1	None	>1200	1246
77	63.94	14.49	7.99	13.49	0	0	0	0.1	None	>1200	1225
78	63.94	12.49	9.99	13.49	0	0	0	0.1	None	>1200	1256
79	63.94	13.49	8.99	11.49	2	0	0	0.1	None	>1200	1216
80	63.94	14.49	6.99	14.49	0	0	0	0.1	None	>1200	1200
81	63.94	12.49	10.99	12.49	0	0	0	0.1	None	>1200	1281
82	63.94	11.99	11.99	11.99	0	0	0	0.1	None	>1200	1302
83	63.94	13.49	7.99	13.49	0	1	0	0.1	None	>1200	1225
84	63.94	13.49	6.99	13.49	0	2	0	0.1	None	>1200	1208
85	68.67	9.68	0	13.37	2.27	5.29	0.53	0.18	None	>1170	1165
86	68.67	9.54	0	13.51	2.27	5.29	0.53	0.18	Trace	<1200	1163
15	70.194	8.6009	0	14.283	1.1848	5.098	0.4377	0.1751	None	>1200	1217
14	70.223	8.8623	0	13.422	1.6727	5.1828	0.4383	0.1716	None	>1200	1215
87	71.27	8.24	0	12.9	2.08	4.85	0.48	0.17	None	>1200	1236
88	67.2	12.31	0	20.29	0	0	0	0.2	Medium	<1150	1117
89	67.01	12.35	0.36	20.08	0	0	0	0.2	High	<1150	1120
90	66.82	12.38	0.72	19.88	0	0	0	0.2	High	<1150	1123
91	68.32	11.82	0.69	18.97	0	0	0	0.2	None	>1150	1167
92	67.77	10.84	0.36	20.83	0	0	0	0.2	Trace	<1150	1131
93	67.57	10.88	0.72	20.63	0	0	0	0.2	Trace	<1150	1134
94	67.2	11.31	0	19.29	0	2	0	0.2	Medium	<1150	1125
95	67.02	11.34	0.36	19.08	0	2	0	0.2	Medium	<1150	1129
96	66.82	11.38	0.72	18.88	0	2	0	0.2	Trace	<1150	1131
97	68.7	10.74	0	18.36	0	2	0	0.2	None	>1150	1170
98	68.52	10.78	0.34	18.16	0	2	0	0.2	None	>1150	1173
99	68.31	10.82	0.69	17.98	0	2	0	0.2	None	>1150	1175
100	66.14	10.19	0.58	14.16	2.37	5.75	0.59	0.21	Medium	<1150	1103
101	66	12.3	0.6	14.2	0.35	4.75	1.6	0.2	None	>1150	1145
102	61.88	13.97	5.99	17.96	0	0	0	0.2	Trace	<1100	1105
103	68.67	10.04	0.56	12.46	2.27	5.29	0.53	0.18	None	>1190	1182
104	63.94	13.49	5.99	13.49	0	3	0	0.1	None	>1200	1192
105	69.06	9.59	0	13.03	2.28	5.32	0.53	0.18	None	>1190	1177
106	68.7	11.74	0	19.36	0	0	0	0.2	Trace	<1150	1162
107	68.52	11.78	0.34	19.16	0	0	0	0.2	Trace	<1150	1165
108	67.96	13.05	0	18.79	0	0	0	0.2	Trace	<1150	1150
109	67.78	13.08	0.36	18.58	0	0	0	0.2	Medium	<1150	1153
110	67.58	13.12	0.72	18.38	0	0	0	0.2	Trace	<1150	1156
111	69.57	8.43	0	13.95	1.16	6.18	0.5	0.18	None	>1200	1206
112	69.9	8.3	0	13.81	1.15	6.14	0.49	0.18	None	>1200	1215
113	69.4	8.36	0	14.29	1.06	6.18	0.5	0.18	None	>1200	1201
114	69.95	8.23	0	14.01	1.04	6.07	0.5	0.18	None	>1200	1217

Table 3. Glass compositions that satisfy equation (3).

									Breakdown	Predicted breakdown	35kp	margin
Sample	SiO_2	Al_2O_3	$\mathrm{B}_2\mathrm{O}_3$	Na_2O	K_2O	MgO	CaO	SnO_2	T(°C)	T(°C)	prediction	predict
6	66.01	11.25	0.6	14.2	1.35	4.76	1.61	0.2	1120	1124	1113	11
38	66	12.25	0.6	14.25	0.35	3.75	2.6	0.2	<1150	1146	1096	50
41	65.35	11.19	1.58	14.06	1.34	4.7	1.58	0.2	<1150	1124	1100	24
29	73.51	7.6	0	11.58	2.3	4.2	0.6	0.2	>1250	1299	1175	124
43	72.55	8.2	0	11.8	2.3	4.35	0.6	0.2	>1190	1273	1178	95
44	71.6	8.85	0	12	2.3	4.45	0.6	0.2	>1190	1248	1184	64
45	70.7	9.45	0	12.2	2.3	4.55	0.6	0.2	>1190	1225	1188	37
46	69.75	10.05	0	12.4	2.3	4.7	0.6	0.2	>1190	1200	1192	8
47	69.87	8.77	0.56	12.67	2.27	5.14	0.53	0.18	>1170	1209	1157	52
48	71.04	8	0.56	12.42	2.27	4.99	0.53	0.18	>1170	1240	1151	89
49	72.22	7.22	0.56	12.17	2.27	4.84	0.53	0.18	>1170	1270	1145	125
50	70.43	8.77	0	12.67	2.27	5.14	0.53	0.18	>1170	1214	1167	47
51	71.61	7.99	0	12.42	2.27	4.99	0.53	0.18	>1170	1245	1162	83
52	72.78	7.22	0	12.17	2.27	4.84	0.53	0.18	>1170	1275	1156	119
16	70.72	8.67		13	2.16	5.19	0.05	0.17	>1190	1220	1187	33
16	70.72	8.67	0	13	2.16	5.19	0.05	0.17	1220	1220	1187	33
53	71.61	7.99	0	12.95	2.27	4.99	0	0.18	>1190	1239	1176	63
30	73.14	7.19	0	12.54	2.16	4.72	0.05	0.18	>1250	1283	1175	108
54	72.22	7.22	0	12.17	3.36	4.84	0	0.18	>1190	1238	1158	80
55	72.22	7.22	0	14.26	2.27	3.84	0	0.18	>1190	1242	1123	119
56	72.22	7.22	0	13.26	3.27	3.84	0	0.18	>1190	1230	1127	103
57	73.5	7.6	0	12.75	1.15	4.2	0.6	0.2	>1200	1312	1169	143
58	73.5	7.6	0	13.9	0	4.2	0.6	0.2	>1200	1327	1164	163
59	72.55	8.2	0	12.95	1.15	4.35	0.6	0.2	>1200	1288	1174	114
60	72.55	8.2	0	14.1	0	4.35	0.6	0.2	>1200	1302	1169	133
61	73.94	7.65	0	13.98	0	4.23	0	0.2	>1200	1337	1198	139
62	72.98	8.25	0	14.19	0	4.38	0	0.2	>1200	1311	1202	109
63	73.5	7.6	0	11.6	2.3	4.2	0.6	0.2	>1200	1298	1174	124
31	73.52	7.6	0	13.87	0	4.2	0.61	0.2	>1260	1328	1165	163
102	61.88	13.97	5.99	17.96	0	0	0	0.2	<1100	1105	1072	33
2	63.94	11.99	5.99	15.98	2	0	0	0.1	1115	1126	1046	80
4	63.94	11.99	5.99	13.99	2	2	0	0.1	1150	1144	1107	37
64	62.93	12.99	5	16.98	2	0	0	0.1	<1100	1077	1051	26
10	68.07	9.72	0.57	13.21	2.31	5.39	0.54	0.18	1160	1160	1155	5
11	68.68	9.54	0.56	12.92	2.27	5.29	0.53	0.18	1180	1178	1163	15
8	67.85	9.21	0.54	14.16	2.34	5.22	0.46	0.19	1140	1145	1122	23
71	68.67	8.54	0.56	13.96	2.27	5.29	0.53	0.18	<1190	1167	1114	53
72 73	71.15	7.78	0.51	12.93	2.09	4.87	0.49	0.18	>1190	1240	1140	100
73	71.16	8.03	0	13.18	2.09	4.87	0.49	0.18	>1190	1230	1146	84
74 75	63.94	12.99	8.99	13.99	0	0	0	0.1	>1200	1236	1119	117
75 76	63.94	13.49	8.99	13.49	0	0	0	0.1	>1200	1241	1143	98
76	63.94	13.99	8.99	12.99	0	0	0	0.1	>1200	1246	1166	80
77	63.94	14.49	7.99	13.49	0	0	0	0.1	>1200	1225	1178	47

										Predicted		
C 1	a.o	A1.0	D.O	N. O	IZ O	M 0	0.0	G 0	Breakdown	breakdown	35kp	margin
Sample	SiO_2	Al_2O_3	B_2O_3	Na ₂ O	K_2O	MgO	CaO	SnO_2	T(°C)	T(°C)	prediction	predict
78 79	63.94	12.49	9.99	13.49	0	0	0	0.1	>1200	1256	1107	149
	63.94	13.49	8.99	11.49	2	0	0	0.1	>1200	1216	1151	65 33
80	63.94	14.49	6.99	14.49	0	0	0	0.1	>1200	1200	1167	33
81	63.94	12.49	10.99	12.49	0	0	0	0.1	>1200	1281	1119	162
82 83	63.94	11.99	11.99	11.99 13.49	0	0	0	0.1	>1200	1302	1107	195
83 84	63.94 63.94	13.49 13.49	7.99	13.49	0	1 2	0	0.1 0.1	>1200 >1200	1225 1208	1162 1181	63
85	68.67	9.68	6.99	13.49	2.27	5.29	0.53	0.18	>1200	1208	1161	27 3
03 105	69.06	9.08 9.59	0	13.03	2.27	5.32	0.53	0.18	>1170	1103	1170	3 7
32	65.7	9.39 8	10	15.7	0.6	0	0.55	0.18	>1190	1262	948	314
86	68.67	9.54	0	13.51	2.27	5.29	0.53	0.08	<1200	1163	1155	8
15	70.19	9.54 8.6	0	14.28	1.19	5.1	0.33	0.18	1215	1217	1149	68
13	70.19	8.86	0	13.43	1.67	5.18	0.44	0.18	1213	1217	1169	47
87	70.23	8.24	0	12.9	2.08	4.85	0.41	0.17	>1210	1216	1159	77
28	72.16	8.13	0	13.27	1.03	4.81	0.43	0.17	>1200	1277	1177	100
22	69.41	8.55	0	14.05	1.19	6.17	0.42	0.10	1215	1199	1177	43
24	70.92	8.52	0	13.7	1.17	5.11	0.36	0.19	>1213	1241	1171	70
20	70.32	8.68	0.03	14.22	1.17	5.06	0.49	0.19	1215	1216	1149	67
23	65.19	10.19	6.2	12.06	2.68	1.81	0.78	0.16	1215	1215	1068	137
12	69.25	9.03	0.29	13.41	2.21	5.04	0.47	0.18	1185	1186	1147	39
17	69.96	8.60	0.55	14.03	1.21	4.97	0.45	0.10	1215	1222	1145	77
18	69.85	8.71	0.05	14.27	1.26	5.18	0.47	0.19	1213	1208	1147	61
19	69.86	8.65	0.03	14.17	1.20	5.05	0.49	0.18	1220	1219	1150	69
33	65.91	10.3	6.27	12.19	2.71	1.83	0.79	0.10	1230	1195	1063	132
13	62.26	13.27	9.6	14.87	0	0	0.75	0.1	1195	1195	1086	109
9	64.8	12.8	4.8	17.6	0	0	0	0	1150	1155	1085	70
7	67.34	12.33	0	20.33	0	0	0	0	1125	1115	1083	32
88	67.2	12.31	0	20.29	0	0	0	0.2	<1150	1117	1084	33
89	67.01	12.35	0.36	20.08	0	0	0	0.2	<1150	1120	1084	36
90	66.82	12.38	0.72	19.88	0	0	0	0.2	<1150	1123	1084	39
106	68.7	11.74	0	19.36	0	0	0	0.2	<1150	1162	1102	60
107	68.52	11.78	0.34	19.16	0	0	0	0.2	<1150	1165	1102	63
91	68.32	11.82	0.69	18.97	0	0	0	0.2	>1150	1167	1102	65
108	67.96	13.05	0	18.79	0	0	0	0.2	<1150	1150	1141	9
109	67.78	13.08	0.36	18.58	0	0	0	0.2	<1150	1153	1142	11
110	67.58	13.12	0.72	18.38	0	0	0	0.2	<1150	1156	1142	14
92	67.77	10.84	0.36	20.83	0	0	0	0.2	<1150	1131	1036	95
93	67.57	10.88	0.72	20.63	0	0	0	0.2	<1150	1134	1036	98
94	67.2	11.31	0	19.29	0	2	0	0.2	<1150	1125	1098	27
95	67.02	11.34	0.36	19.08	0	2	0	0.2	<1150	1129	1099	30
96	66.82	11.38	0.72	18.88	0	2	0	0.2	<1150	1131	1099	32
97	68.7	10.74	0	18.36	0	2	0	0.2	>1150	1170	1117	53
98	68.52	10.78	0.34	18.16	0	2	0	0.2	>1150	1173	1117	56
99	68.31	10.82	0.69	17.98	0	2	0	0.2	>1150	1175	1117	58
111	69.57	8.43	0	13.95	1.16	6.18	0.5	0.18	>1200	1206	1155	52
112	69.9	8.3	0	13.81	1.15	6.14	0.49	0.18	>1200	1215	1158	58
113	69.4	8.36	0	14.29	1.06	6.18	0.5	0.18	>1200	1201	1146	55
114	69.95	8.23	0	14.01	1.04	6.07	0.5	0.18	>1200	1217	1153	65

[0042] While typical embodiments have been set forth for the purpose of illustration, the foregoing description should not be deemed to be a limitation on the scope of the disclosure or appended claims. Accordingly, various modifications, adaptations, and alternatives may occur to one skilled in the art without departing from the spirit and scope of the present disclosure or appended claims.

CLAIMS

1. A glass comprising SiO_2 and Na_2O , wherein the glass has a temperature T^{35kp} at which the glass has a viscosity of 35 kpoise, wherein the temperature $T^{breakdown}$ at which zircon breaks down to form ZrO_2 and SiO_2 is greater than T^{35kp} .

- 2. The glass of Claim 1, wherein $SiO_2 + B_2O_3 \ge 66$ mol% and $Na_2O \ge 9$ mol%.
- 3. The glass of Claim 1 or Claim 2, wherein the glass is ion exchangeable.
- 4. The glass of Claim 3, wherein the glass is ion exchanged to form a compressive layer on at least one surface of the glass.
- 5. The glass of Claim 4, wherein the ion exchanged glass has a compressive stress of at least 350 MPa and a compressive depth of layer of at least 20 microns.
- 6. The glass of Claim 4, wherein the ion exchanged glass has a central tension of at least 10 MPa.
- 7. The glass of any of the preceding claims, wherein the glass comprises: 61 mol $\% \le SiO_2 \le 75$ mol%; 7 mol $\% \le Al_2O_3 \le 15$ mol%; 0 mol $\% \le B_2O_3 \le 12$ mol%; 9 mol $\% \le Na_2O \le 21$ mol%; 0 mol $\% \le K_2O \le 4$ mol%; 0 mol $\% \le MgO \le 7$ mol%; and 0 mol $\% \le CaO \le 3$ mol%.
- 8. The glass of any of the preceding claims, wherein $T^{margin} = T^{breakdown} T^{35kp}$, wherein $T^{margin} = 610.6 41.0[Al_2O_3] + 9.9[B_2O_3] 3.5[Na_2O] 20.2[K_2O] 25.6[MgO] + 34.2[CaO]$ where concentrations [Al_2O_3], [B_2O_3], [Na_2O], [K_2O], [MgO], and [CaO] are expressed in mol%, and wherein $T^{margin} \ge 0$.
- 9. The glass of any of the preceding claims, wherein $T^{margin} = T^{breakdown} T^{35kp}$, wherein T^{margin} (°C) = 446.6 50.2[Al₂O₃] + 22.6[B₂O₃] 4.4[Na₂O] -

 $3.9[K_2O] - 1.2[MgO + CaO]$ where concentrations $[Al_2O_3]$, $[B_2O_3]$, $[Na_2O]$, $[K_2O]$, [MgO], and [CaO] are expressed in mol%, and wherein $T^{margin} \ge 0$.

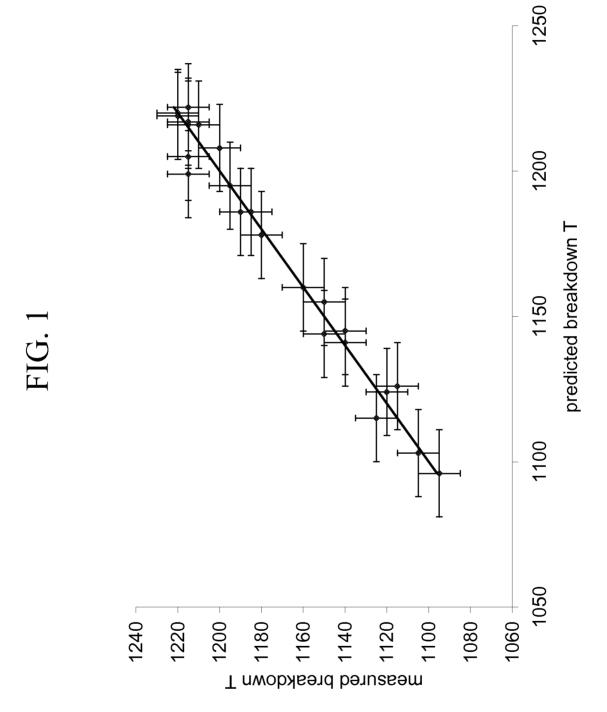
- 10. The glass of any of the preceding claims, wherein the glass is down-drawable.
- 11. The glass of any of the preceding claims, wherein the glass is fusion drawn into a glass sheet.
- 12. The glass of Claim 11, wherein the glass sheet has less than one inclusion of solid ZrO₂ per pound of glass sheet.
- 13. The glass of any of the preceding claims, wherein $B_2O_3 + Na_2O + K_2O + M_gO + CaO \ge 18$ mol%.
- 14. The glass of any of the preceding claims, wherein $B_2O_3 + Na_2O + K_2O Al_2O_3 \ge 0$ mol%.
- 15. The glass of any of the preceding claims, wherein the glass has a liquidus viscosity of greater than about 100 kpoise.
- 16. The glass of any of the preceding claims, wherein the glass has a 350 poise temperature T^{350} of less than or equal to 1650° C.
- 17. The glass of any of the preceding claims, wherein the glass is formed into one of a cover plate, a window, a casing, a display screen, and a touch panel of an electronic device.
- 18. A glass, the glass comprising SiO_2 and Na_2O and having a temperature T^{35kp} at which the glass has a viscosity of 35 kpoise, wherein $SiO_2 + B_2O_3 \ge 66$ mol% and $Na_2O \ge 9$ mol%, and wherein the temperature $T^{breakdown}$ at which zircon breaks down to form ZrO_2 and SiO_2 is greater than T^{35kp} .
 - 19. The glass of Claim 17, wherein the glass is ion exchangeable.

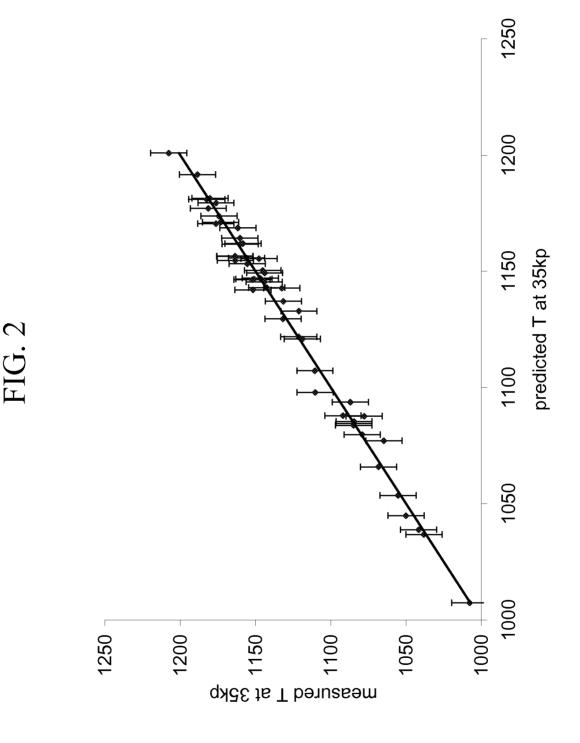
20. The glass of Claim 18, wherein the glass is ion exchanged to form a compressive layer on at least one surface of the glass.

- 21. The glass of Claim 20, wherein the ion exchanged glass has a compressive stress of at least 350 MPa and a compressive depth of layer of at least 20 microns.
- 22. The glass of Claim 20, wherein the ion exchanged glass has a central tension of at least 10 MPa.
- 23. The glass of any of Claims 18-22, wherein the glass comprises: 61 mol $\% \le SiO_2 \le 75$ mol%; 7 mol $\% \le Al_2O_3 \le 15$ mol%; 0 mol% $\le B_2O_3 \le 12$ mol%; 9 mol $\% \le Na_2O \le 21$ mol%; 0 mol $\% \le K_2O \le 4$ mol%; 0 mol% $\le MgO \le 7$ mol%; and 0 mol% $\le CaO \le 3$ mol%.
- 24. The glass of any of Claims 18-23, wherein $T^{margin} = T^{breakdown} T^{35kp}$, wherein $T^{margin} = 610.6 41.0 [Al_2O_3] + 9.9 [B_2O_3] 3.5 [Na_2O] 20.2 [K_2O] 25.6 [MgO] + 34.2 [CaO] where concentrations [Al_2O_3], [B_2O_3], [Na_2O], [K_2O], [MgO], and [CaO] are expressed in mol%, and wherein <math>T^{margin} \ge 0$.
- 25. The glass of any of Claims 18-23, wherein $T^{margin} = T^{breakdown} T^{35kp}$, wherein T^{margin} (°C) = 446.6 50.2[Al₂O₃] + 22.6[B₂O₃] 4.4[Na₂O] 3.9[K₂O] 1.2[MgO + CaO] where concentrations [Al₂O₃], [B₂O₃], [Na₂O], [K₂O], [MgO], and [CaO] are expressed in mol%, and wherein $T^{margin} \ge 0$.
 - 26. The glass of any of Claims 18-25, wherein the glass is down-drawable.
- 27. The glass of any of Claims 18-26, wherein the glass is fusion drawn into a glass sheet.
- 28. The glass of Claim 27, wherein the glass sheet has less than one inclusion of solid ZrO₂ per pound of glass sheet.
- 29. The glass of any of Claims 18-28, wherein $B_2O_3 + Na_2O + K_2O + M_gO + CaO \ge 18 \text{ mol}\%$.

30. The glass of any of Claims 18-29, wherein $B_2O_3 + Na_2O + K_2O - Al_2O_3 \ge 0$ mol%.

- 31. The glass of any of Claims 18-30, wherein the glass has a liquidus viscosity of greater than about 100 kpoise.
- 32. The glass of any of Claims 18-31, wherein the glass has a 350 poise temperature T^{350} of less than or equal to 1650° C.
- 33. The glass of any of Claims 18-32, wherein the glass is formed into one of a cover plate, a window, a casing, a display screen, and a touch panel of an electronic device.





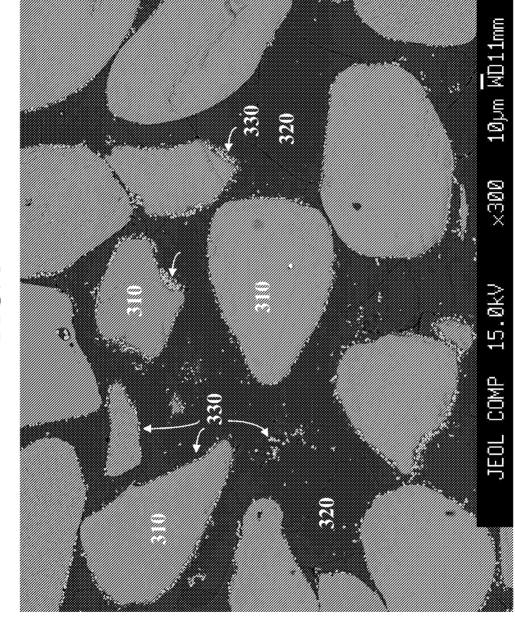


FIG. 3



